

Transition from AMR to GMR Heads in Tape Recording



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80305-5602**

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THIC Inc.

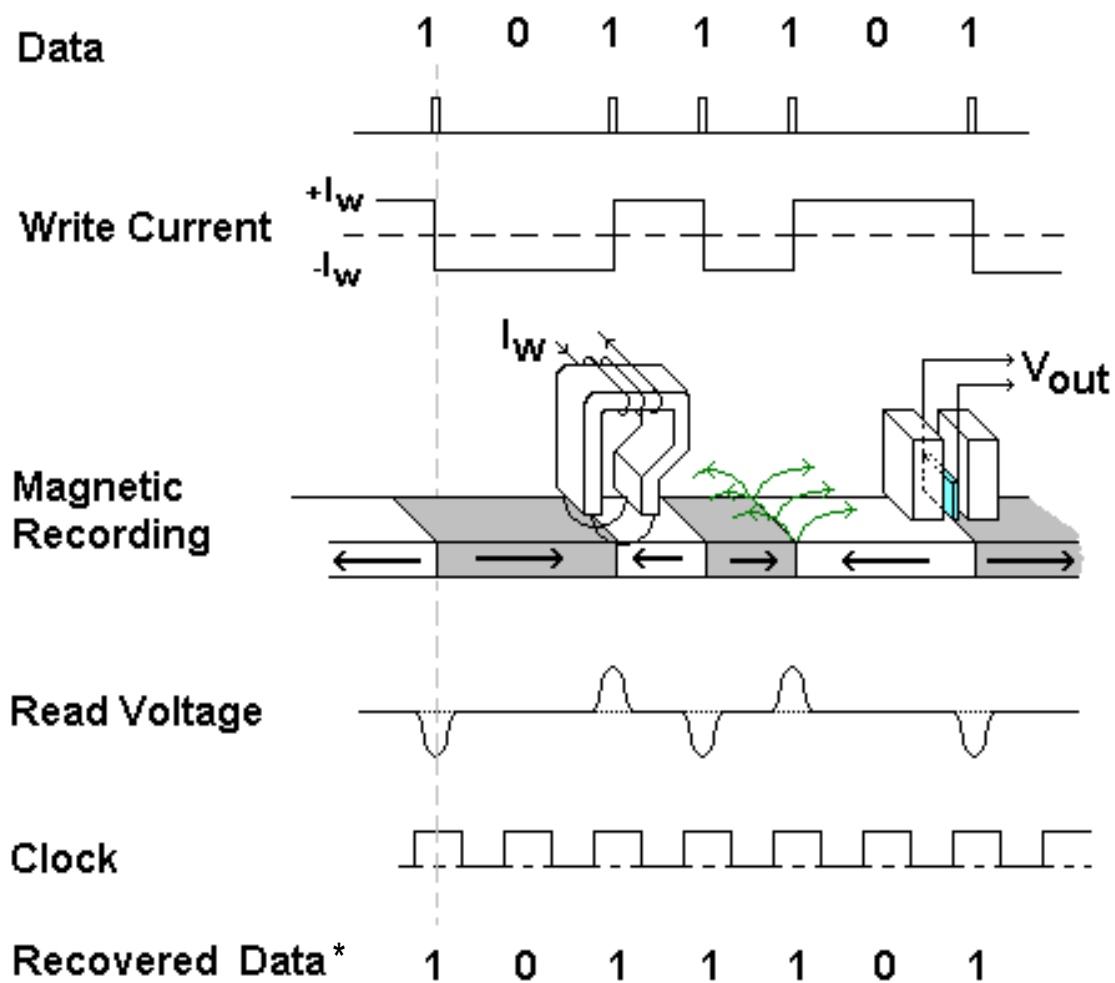
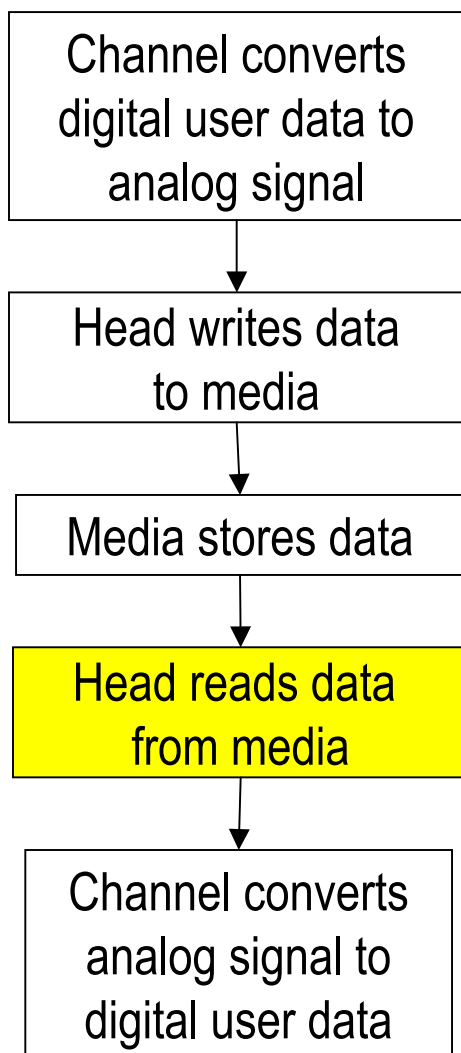
The Premier Advanced Storage Technology Forum



Outline

- Basics of magnetic recording
 - > AMR (Anisotropic Magneto-Resistance)
 - > GMR (Giant Magneto-Resistance)
- Transition in disk from AMR to GMR
- Issues surrounding the transition from AMR to GMR in tape

Digital Magnetic Recording



*Using a peak detect channel

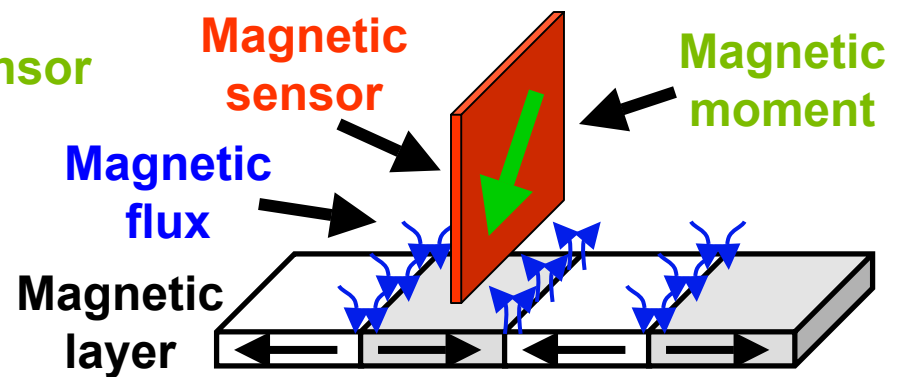
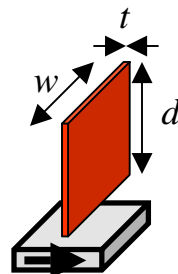
Magnetic Read Sensors

- Allow system to resolve changes in the magnetic media which stores the user information
- Two types in magnetic recording
 - > Inductive: Faraday's Law ($\nabla \times \mathbf{E} = -\frac{\partial \mathbf{B}}{\partial t}$)
 - > Magneto-Resistive (MR): electric resistance of the sensor changes with applied magnetic field

Rotation of the magnetization in a MR sensor gives rise to a resistivity change ($\Delta\rho$)

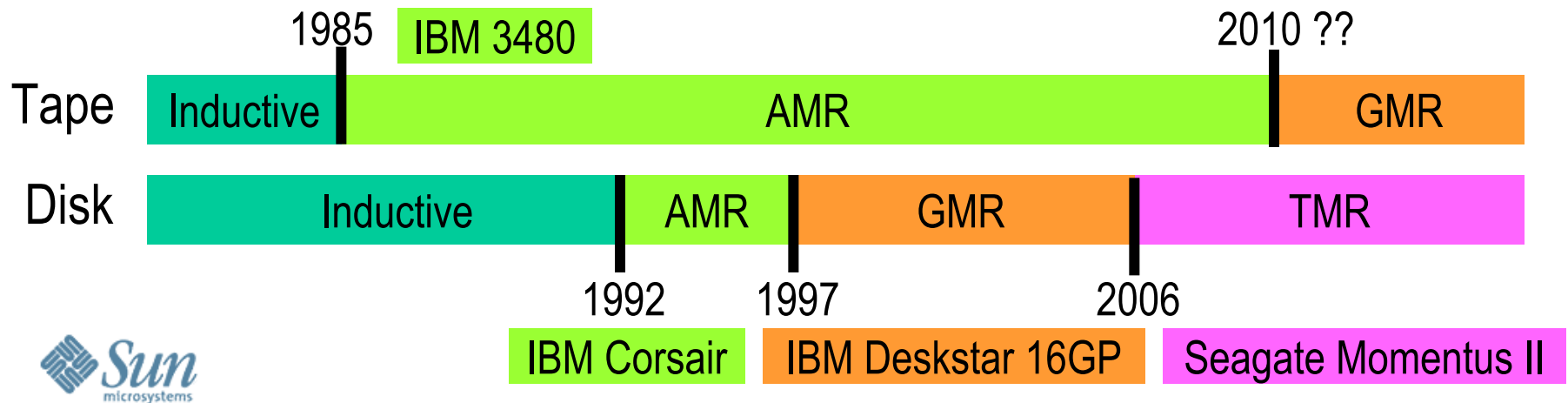
$$\rho = \rho_0 + \Delta\rho \cdot f(\theta)$$

$$\Delta V = I \cdot \Delta R = I \cdot \Delta\rho \cdot \frac{w}{td}$$



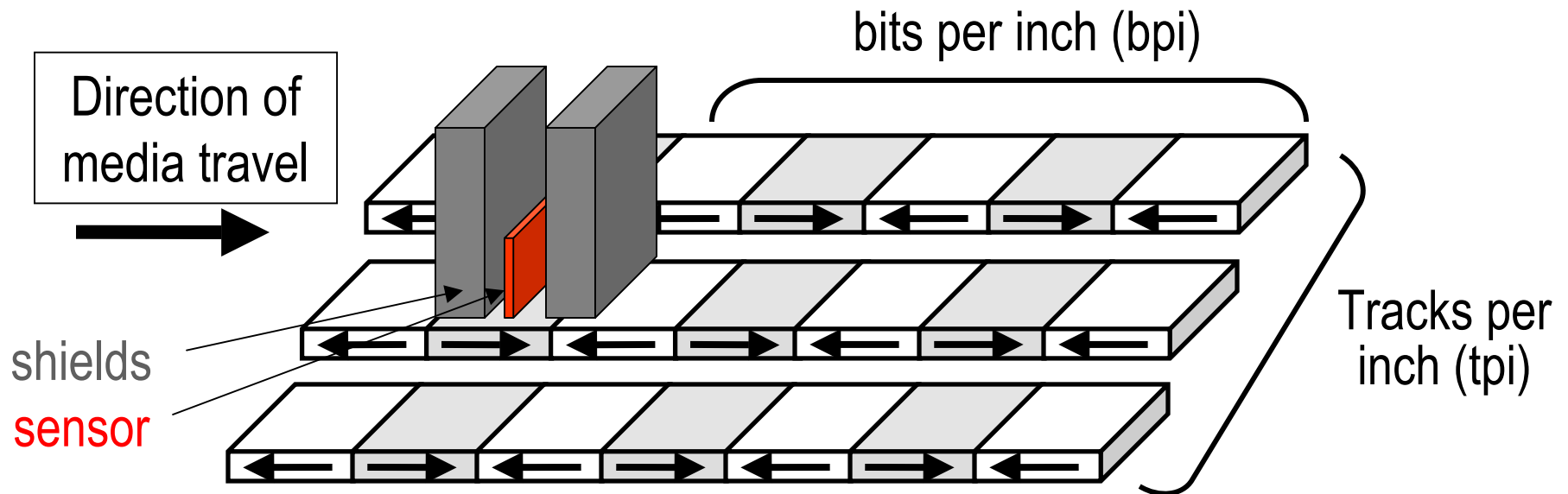
Tape and Disk Sensor Technology

- Inductive
 - > A variable magnetic field from the media will induce a variable voltage in a coil
- Anisotropic magneto-resistance ($\Delta\rho/\rho \sim 2\%$ in $\text{Ni}_{80}\text{Fe}_{20}$)
 - > Bulk effect in ferromagnetic materials
- Giant magneto-resistance ($\Delta\rho/\rho \sim 20\%$ in Co/Cu/Co)
 - > Interface effect in thin multilayers
- Tunneling giant magneto-resistance ($\Delta\rho/\rho \sim 250\%$ in Co/MgO/Co)
 - > Coherent tunneling effect across an insulator

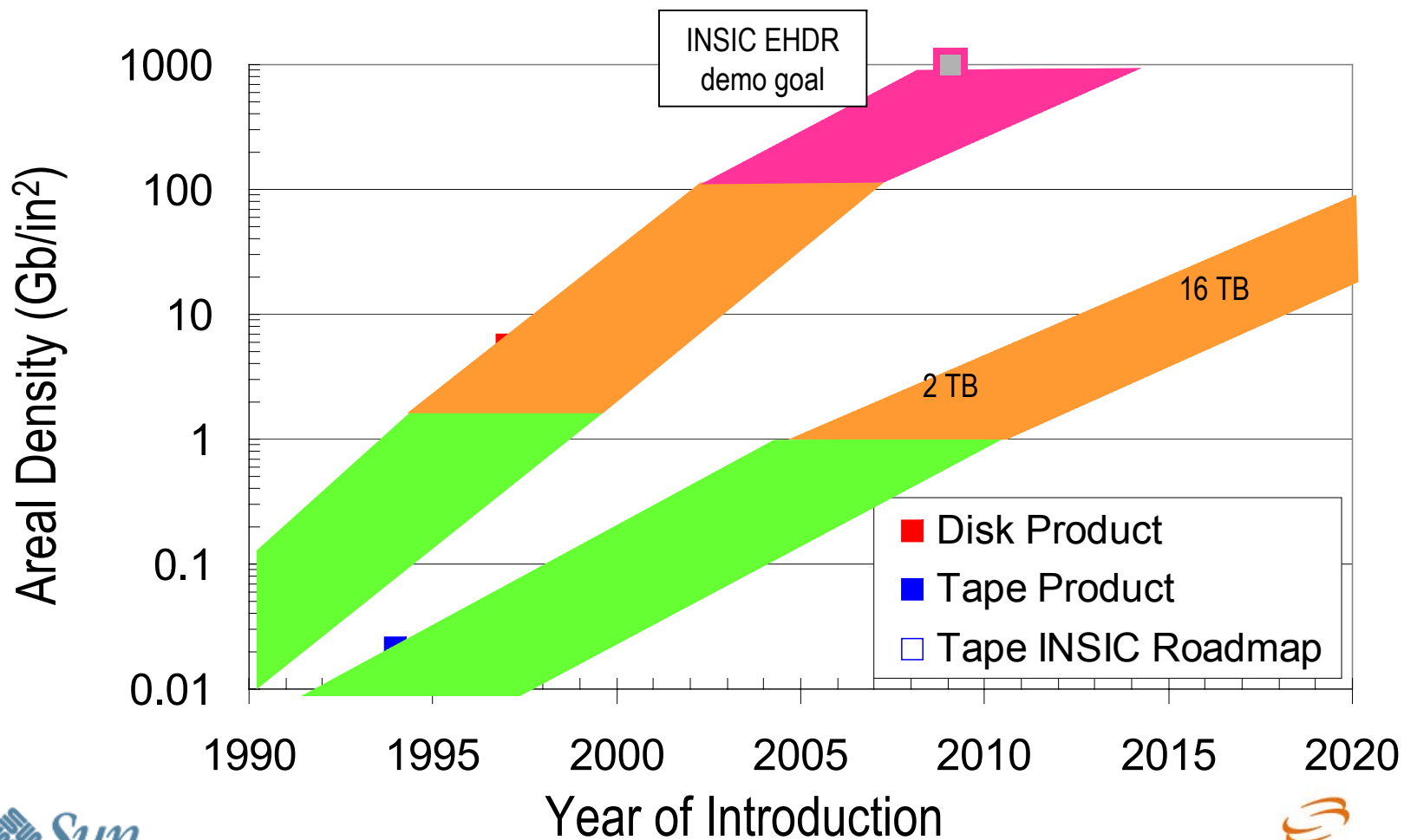
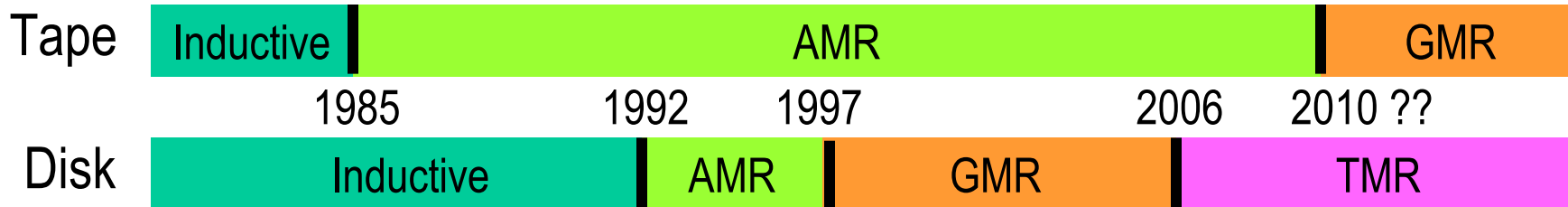


Magnetic Recording

- Tape area – width (1/2”) and length (900 m)
 - > ~ 18,000 in²
- Disk area – area of a platter and number of platters
 - > ~ 8 in² for 1 single-sided platter



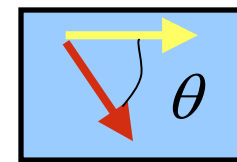
$$\text{Areal density (bits/in}^2\text{)} = \text{tpi} \cdot \text{bpi}$$



AMR Response

- Anisotropic Magneto-Resistance (AMR) is a bulk effect in Permalloy ($\text{Ni}_{80}\text{Fe}_{20}$) and other ferromagnetic materials
 - > Optimum bias at 45 degrees

$$\rho(H) = \rho_0 + \Delta\rho_{AMR} \cos^2 \theta(H)$$

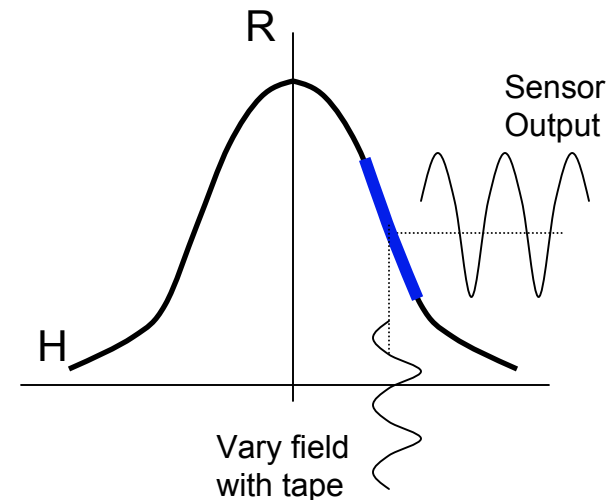
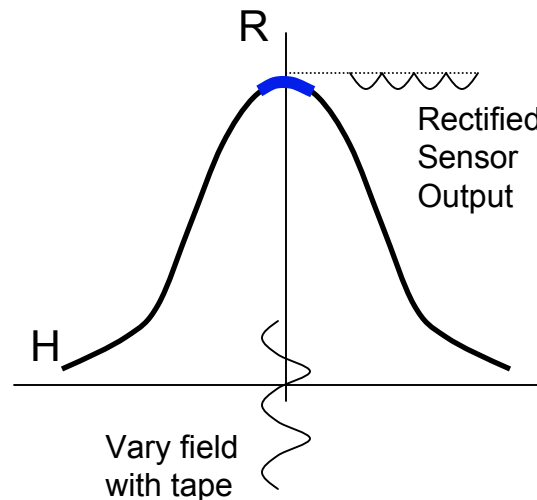


current

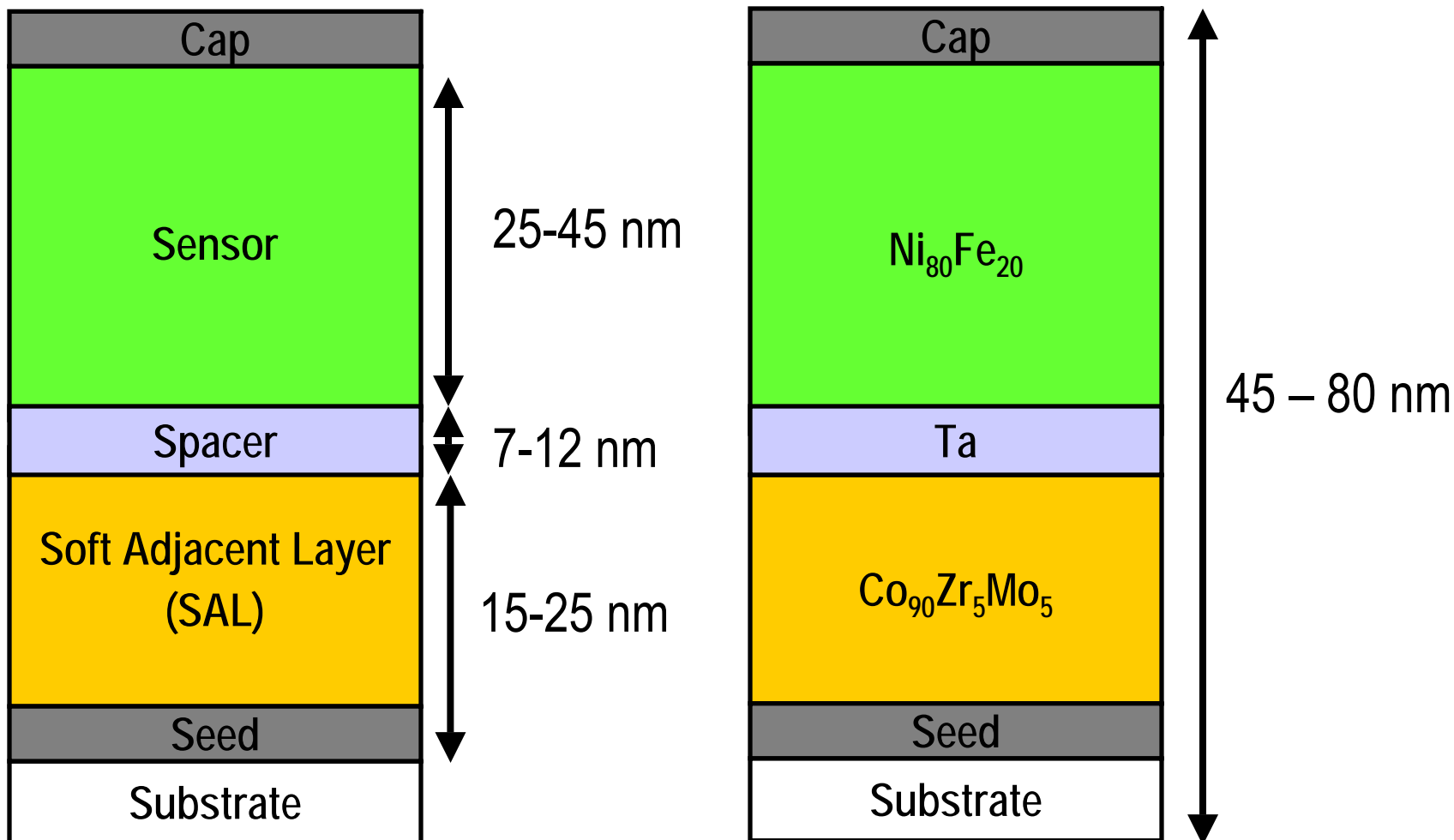
magnetization

AMR:

Goal is to offset the bias field

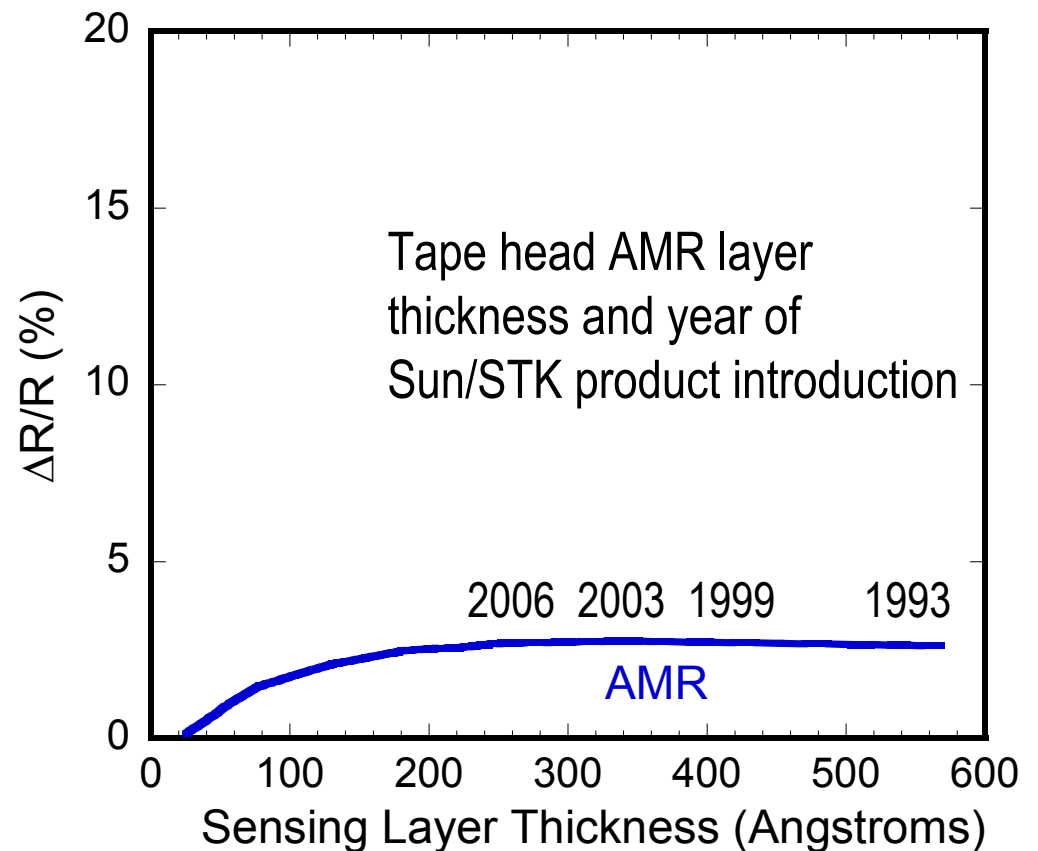


AMR Sensor Stack Materials

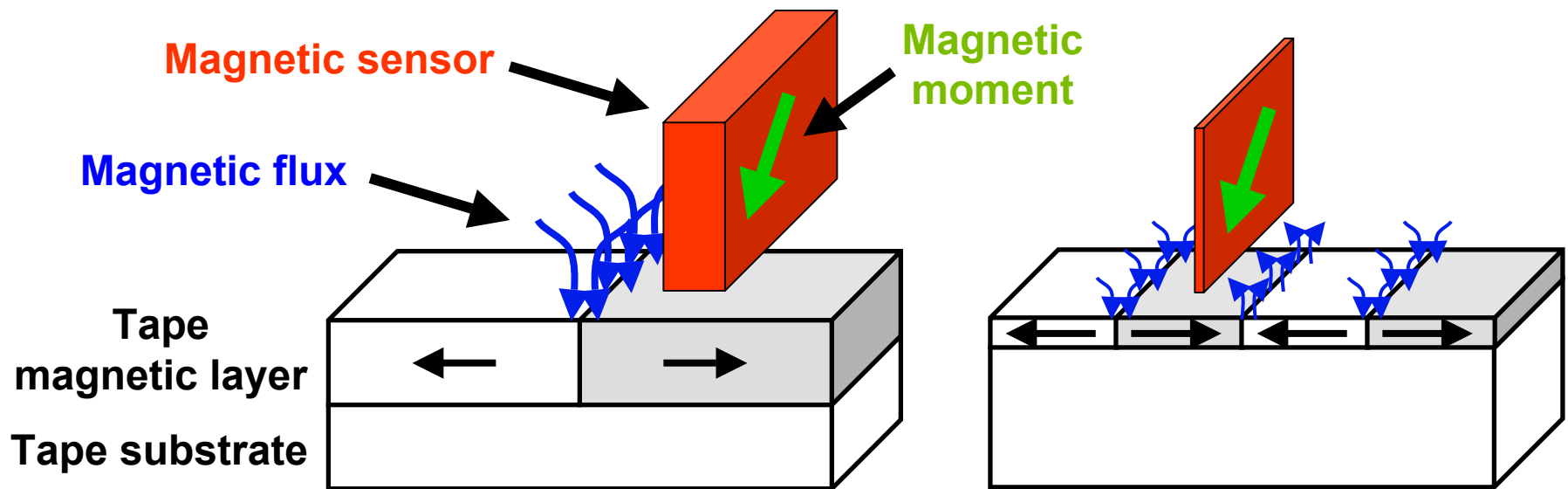


Why Switch from AMR?

- AMR is a good sensor (and still used by tape)
- BUT, it has a problem. Output decreases as sensor thickness decreases
- Why has sensor thickness decreased over time?



Achieving Higher Densities



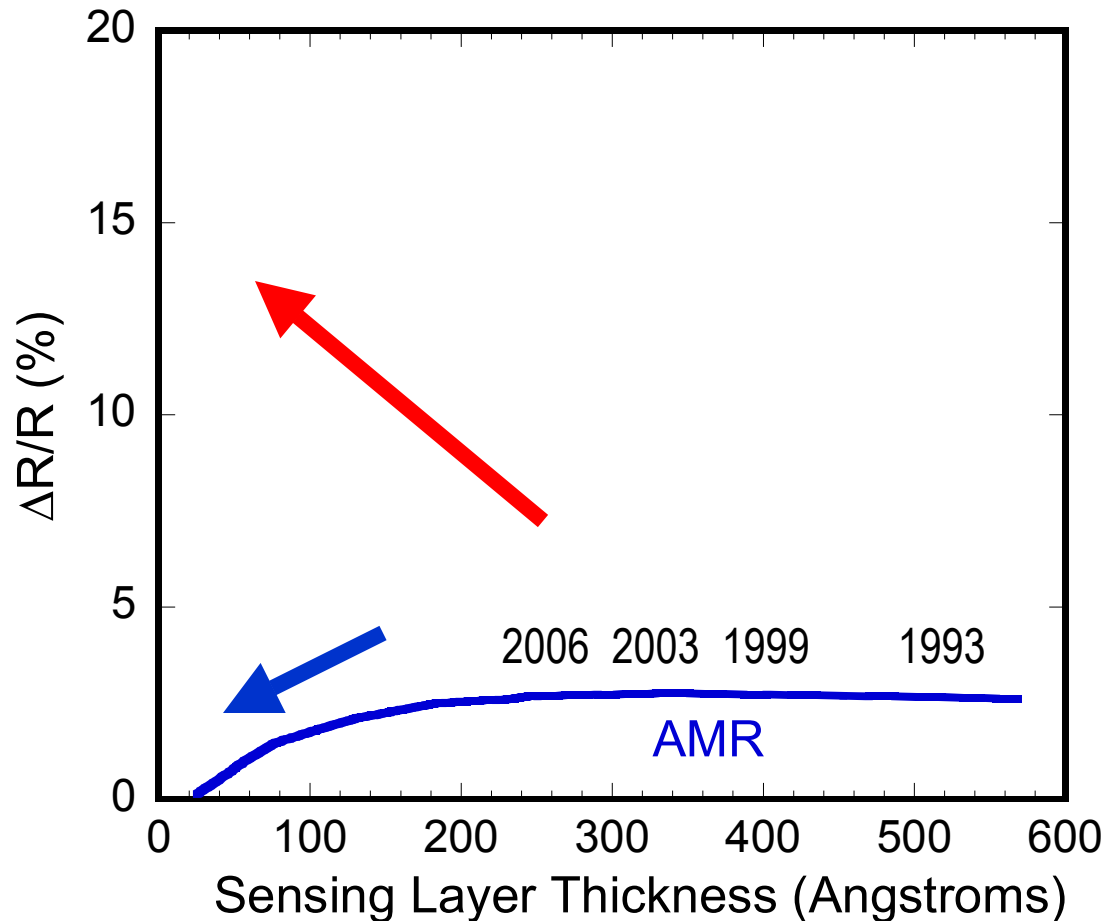
Thick media → low density → lots of flux
Thick sensor to match flux

Thin media → high density → less flux
Thin sensor to match flux

Sensor for higher densities:

1. Thinner sensor (for thinner media)
2. Higher sensitivity (to make up for reduced flux)

Decreasing Thickness Penalty in AMR



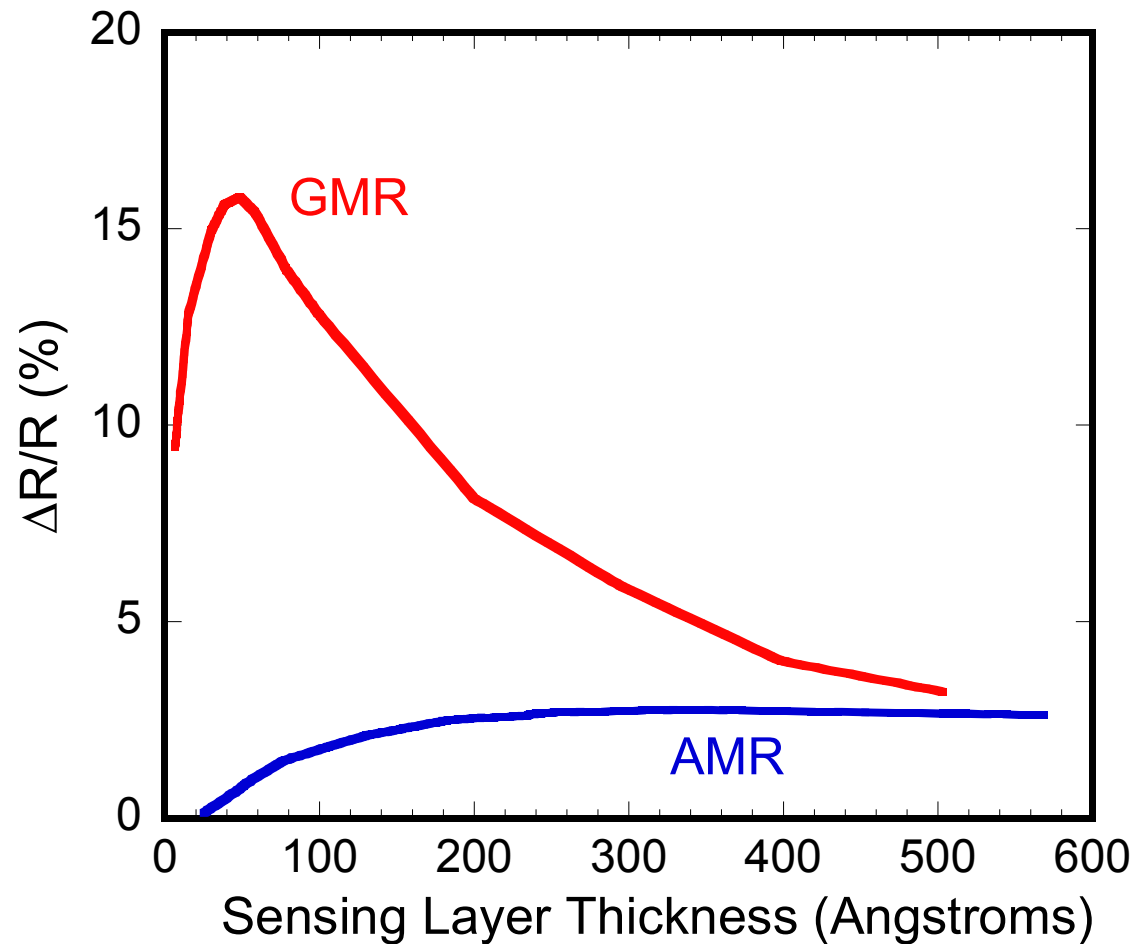
Thinning the sensor allows higher density BUT the signal goes down!

Want something that can increase output with decreasing sensor thickness

Advantage of GMR

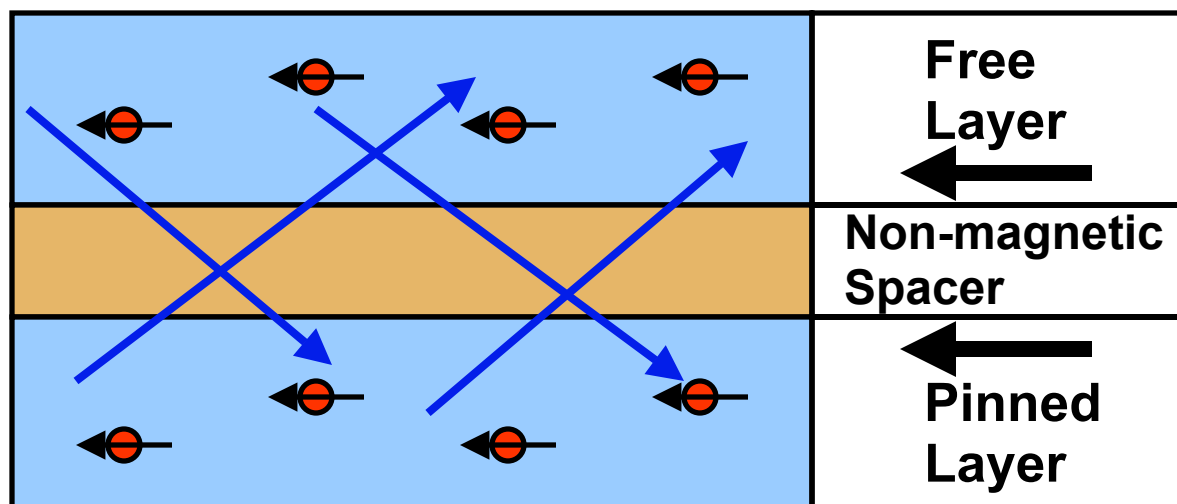
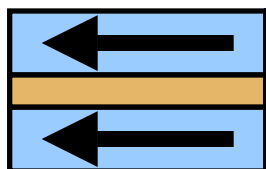
GMR is an interface effect

AMR is a bulk effect, interfacial scattering takes over at small thicknesses

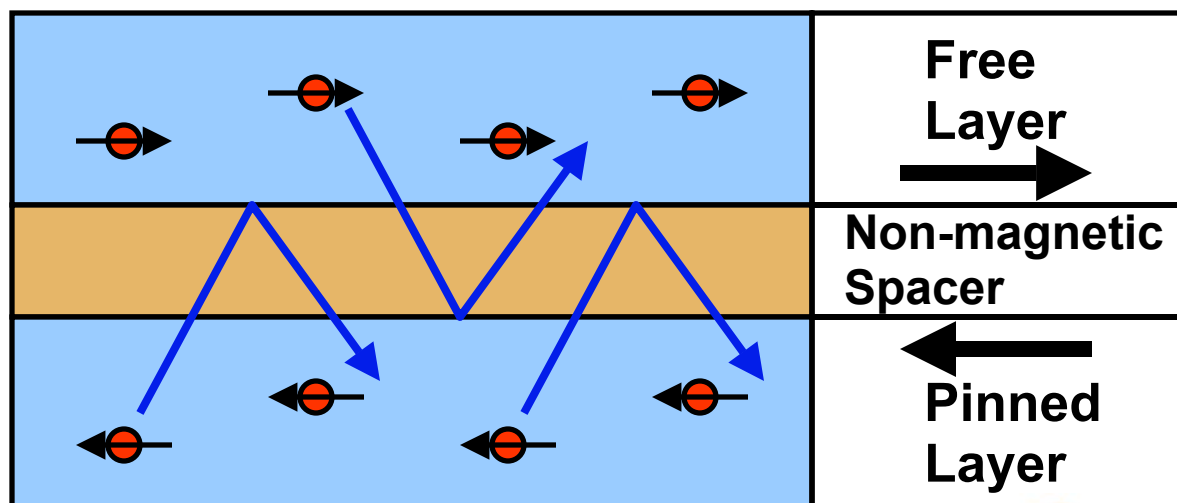
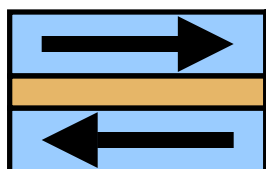


GMR – Spin Dependent Scattering

Aligned moments
Low Resistance



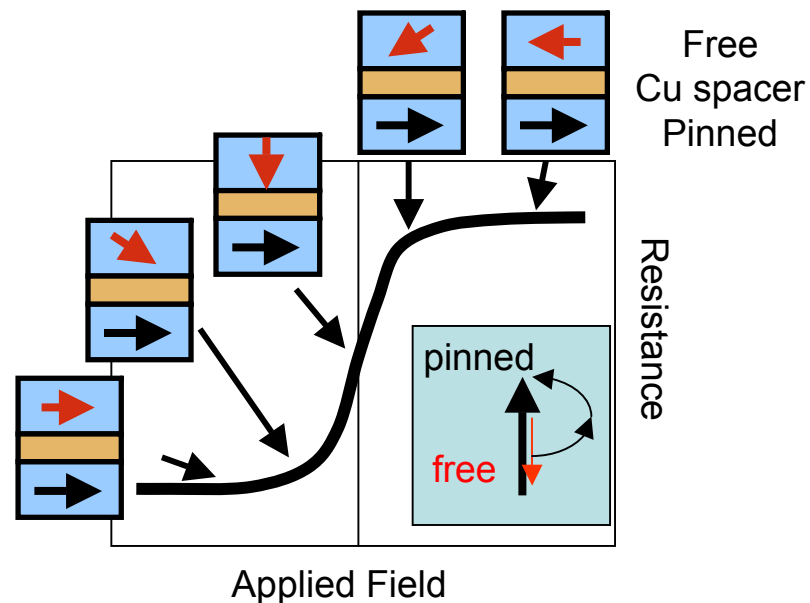
Anti-aligned moments
High Resistance



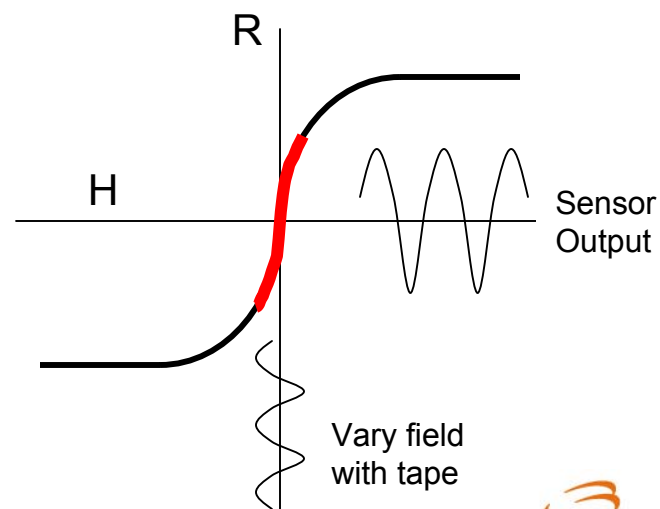
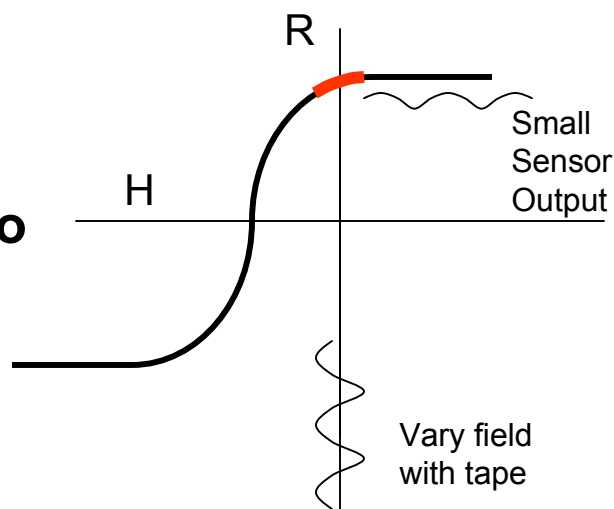
GMR Response

- GMR is an interface effect
 - > Bias at 0 degrees

$$\rho(H) = \rho_0 + \Delta\rho_{GMR} \sin \theta(H)$$

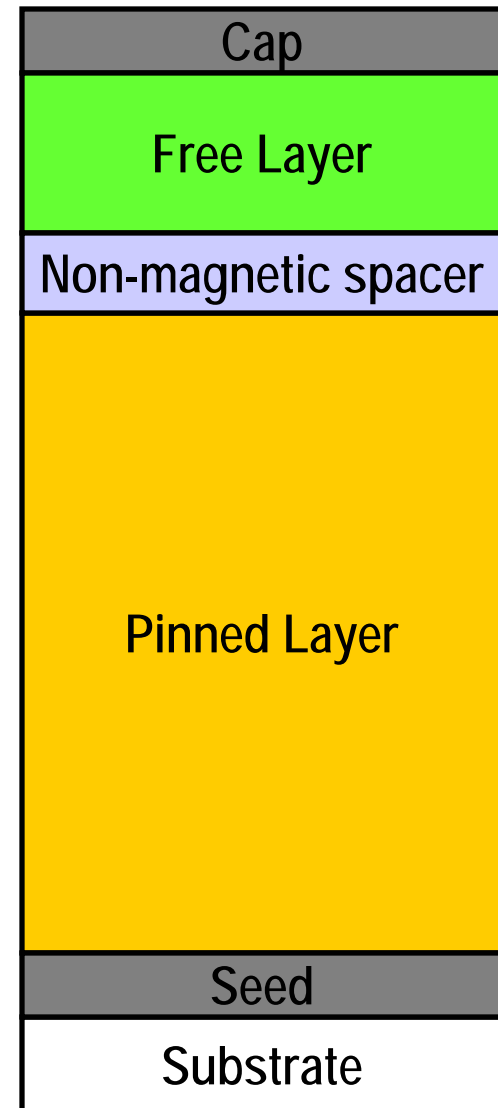


GMR:
Goal is to zero the bias field

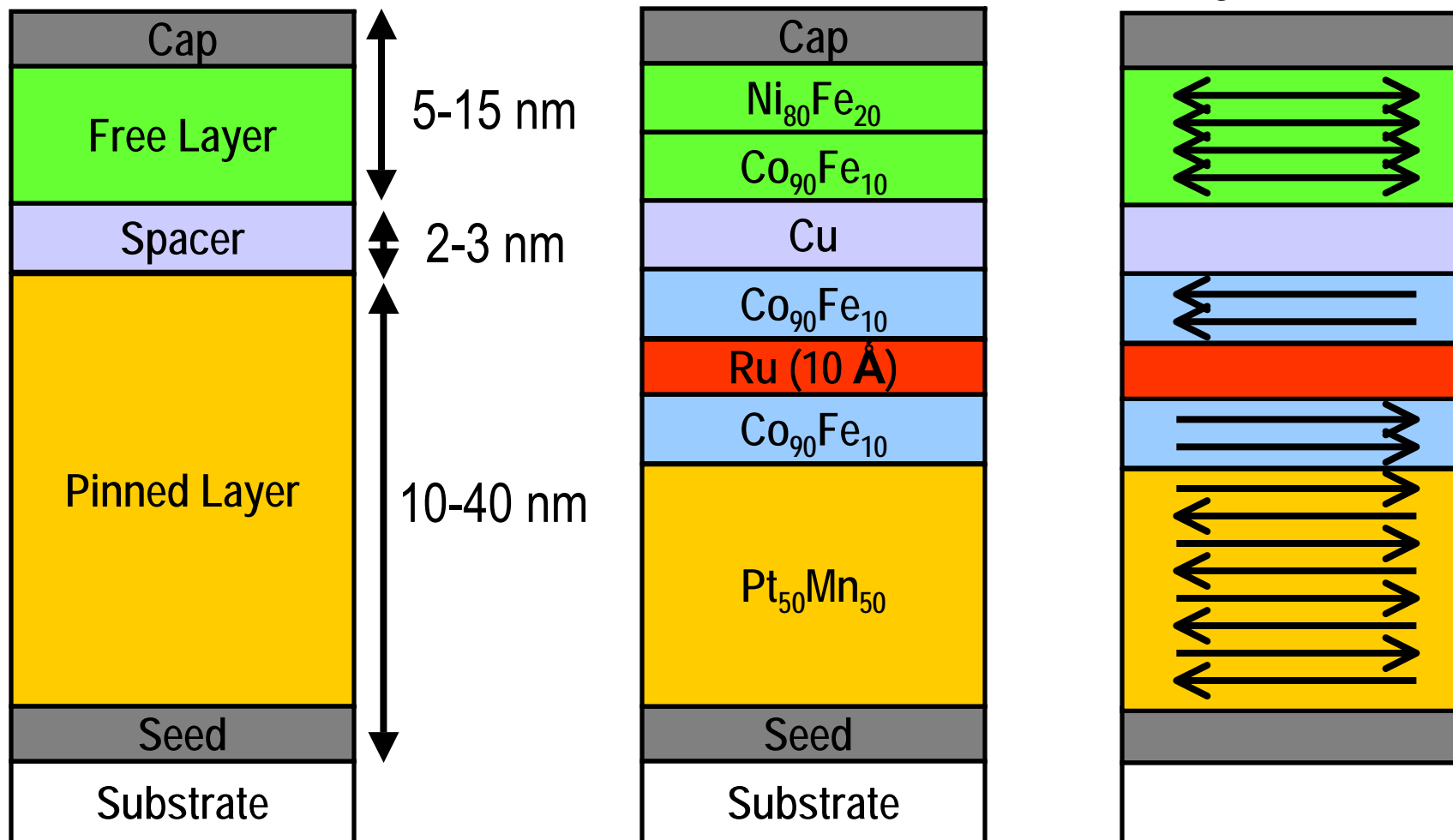


How Do We Make These Structures?

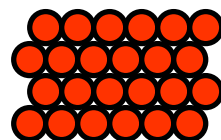
- GMR structures act as a spin valve
 - > Resistance depends on direction of applied magnetic field on the sensor
- 3 important components
 - > Free layer
 - > Well behaved
 - > Properly oriented and biased
 - > Non-magnetic spacer
 - > Interface properties are important
 - > A solid pinned layer
 - > Won't move with field from tape



GMR Sensor Stack Materials



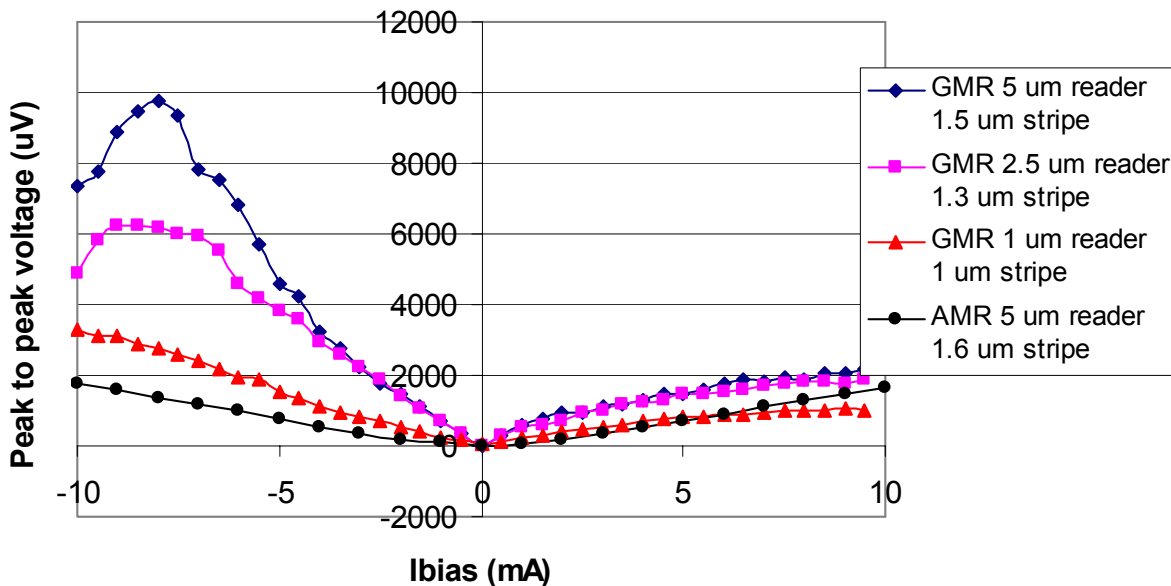
Ru atomic radii $\sim 2.6 \text{ \AA}$



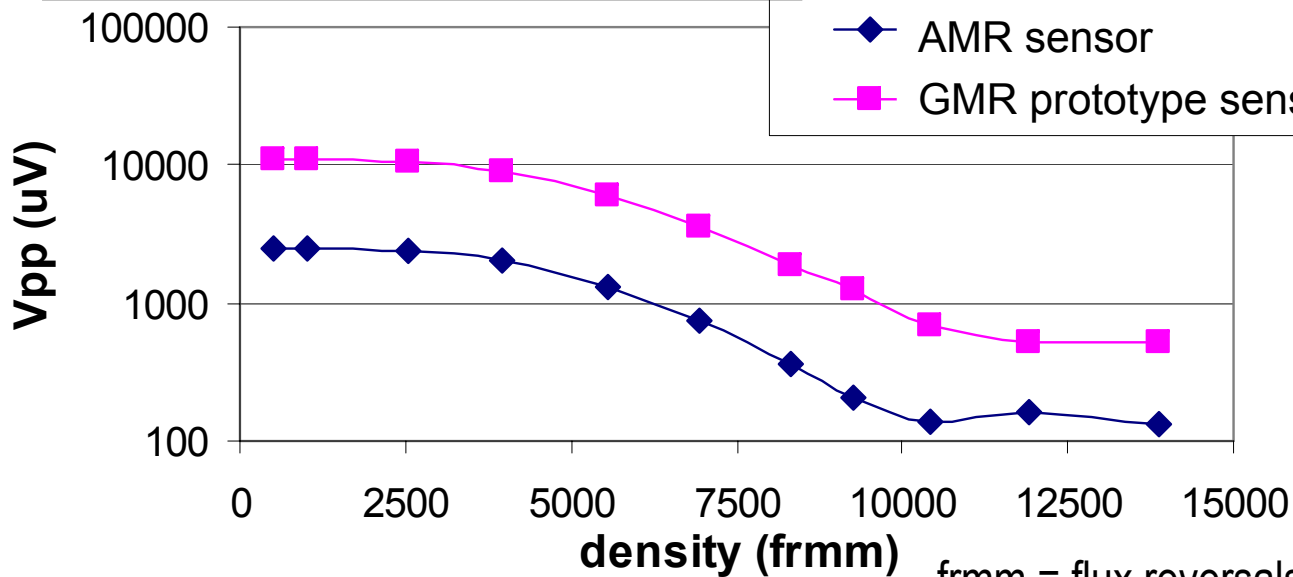
10 \AA

$\text{Å} = 10^{-10} \text{ m}$

GMR at Sun



5 μm reader width comparison



$$\frac{\left(\frac{\Delta R}{R}\right)_{GMR}}{\left(\frac{\Delta R}{R}\right)_{AMR}} = \frac{9\%}{2\%} = 4.5$$

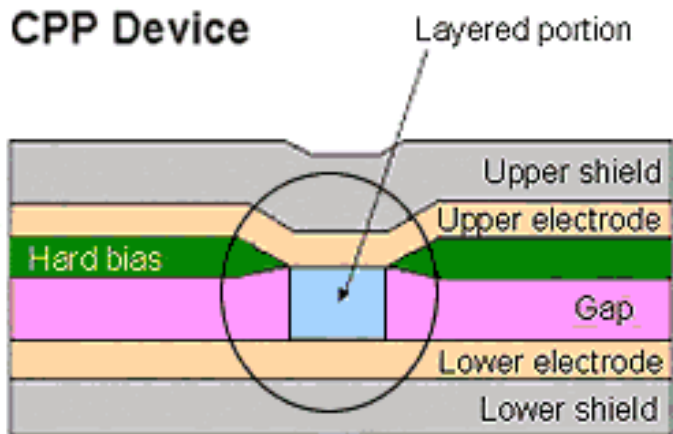
frmm = flux reversals per mm

Recording Head Operations at Sun Louisville, CO

- Providing leading edge head technologies for Enterprise, Mid-Range, and Low-End tape drive products.
 - > Sun Microsystems T10000 and 9x40 product lines; LTO2-LTO4
 - > The first thin film helical scan read & write heads in production with VXA-3
- Developing the technology building blocks for future generation products now
 - > GMR, increased device density, advanced materials
- Custom designed equipment technology to meet the unique requirements of tape head manufacturing
 - > Dynamic testers, head assembly, critical dimension measurement
- State-of-the-art performance analysis capabilities to ensure product quality and competitive position
 - > Dynamic performance, constructional analysis, magnetics analysis

GMR to TMR

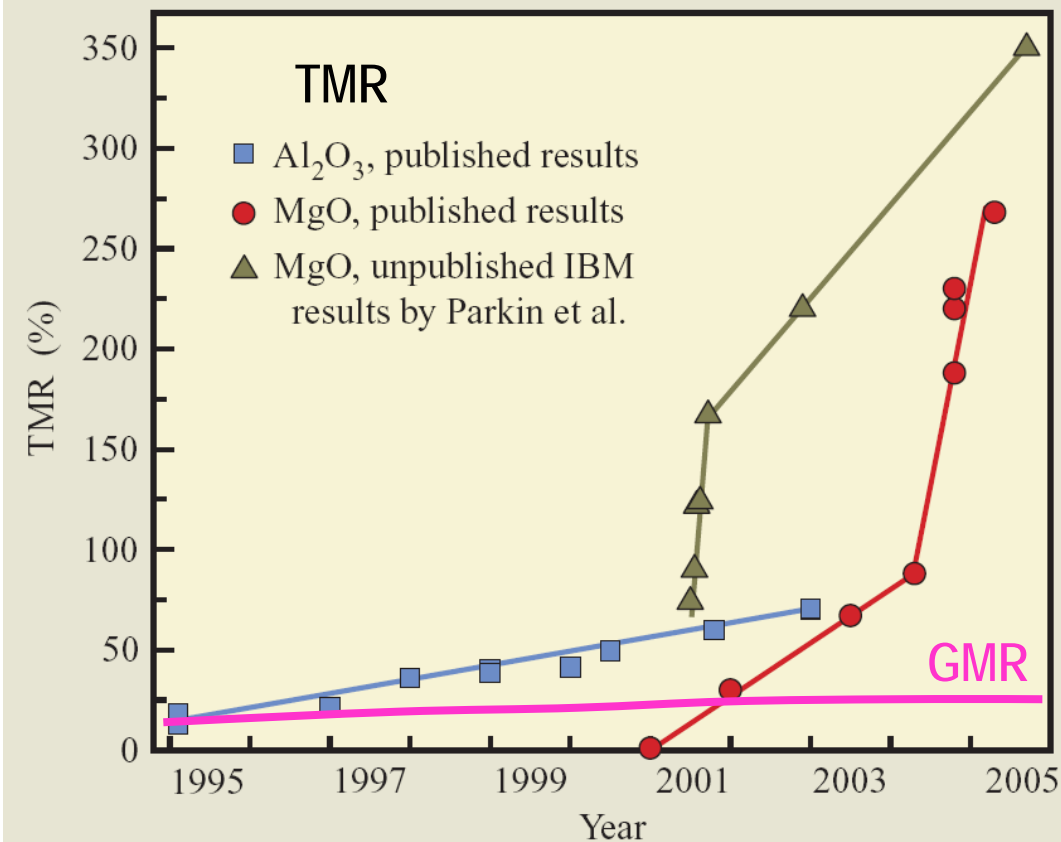
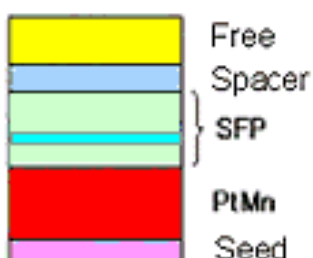
CPP Device



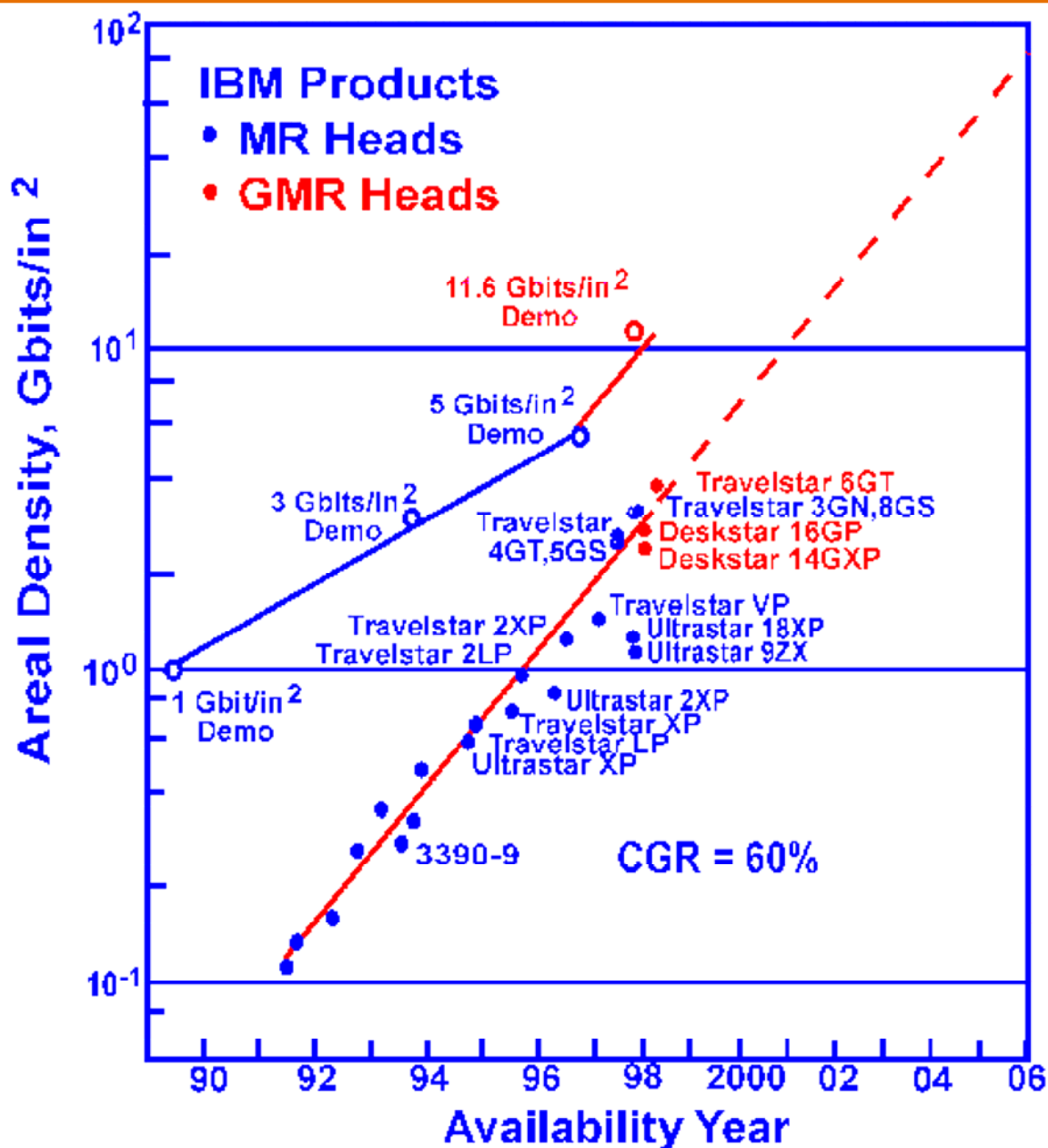
Enlarged View of TMR Layer



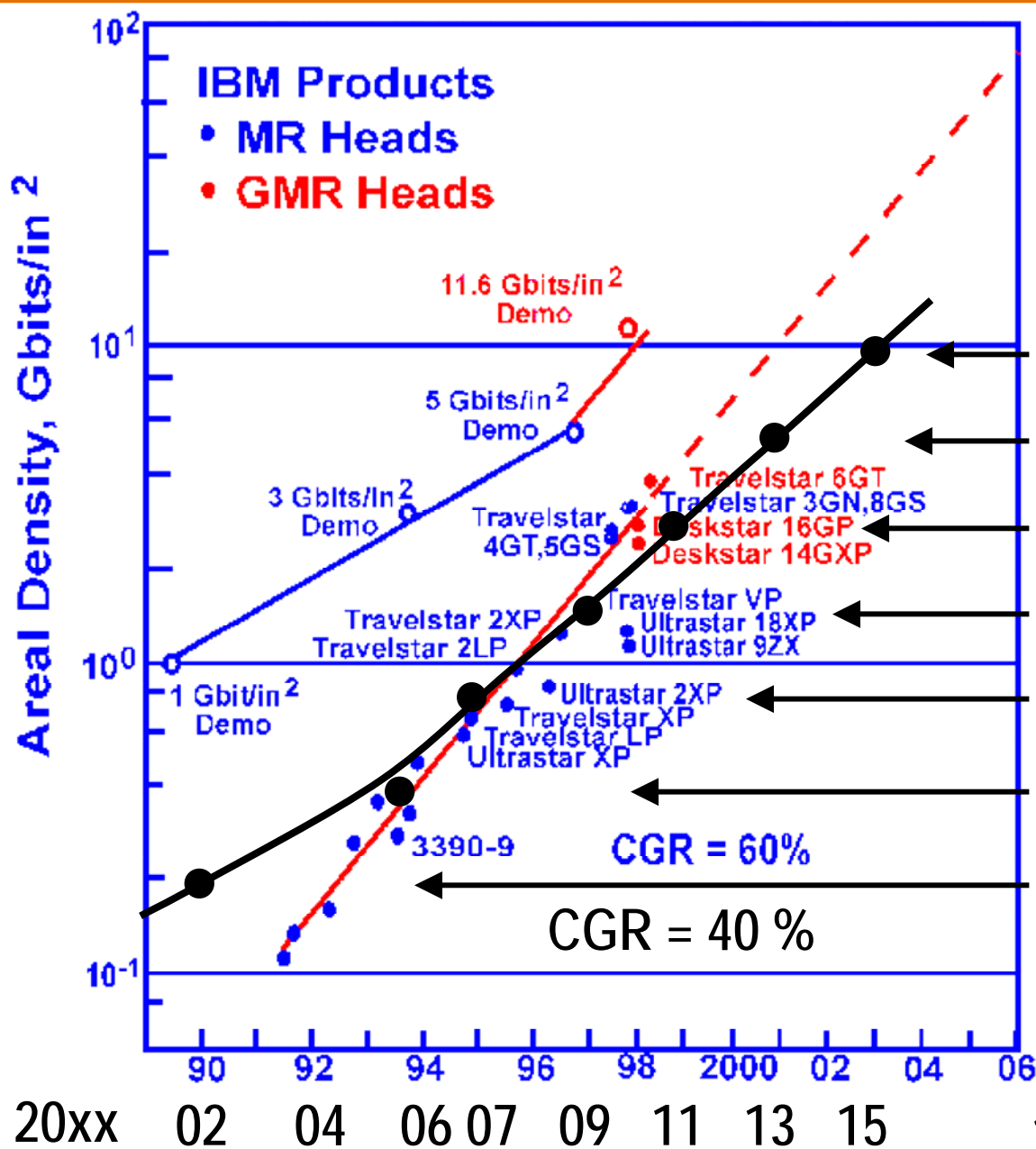
Enlarged View of CPP-GMR Layer



Gallagher and Parkin, IBM J. Res. Dev. 50, 5 (2006)



AMR to GMR Transition for IBM



AMR to GMR Transition for tape

INSIC (2015), 10 Gb/in² (16 TB)

INSIC (2013), 5 Gb/in² (8 TB)

INSIC (2011), 2.7 Gb/in² (4 TB)

INSIC (2009), 1.5 Gb/in² (2 TB)

INSIC (2007), 0.8 Gb/in² (1 TB)

T10000 (2006), 0.4 Gb/in² (500 GB)

9940B (2002), 0.2 Gb/in² (200 GB)

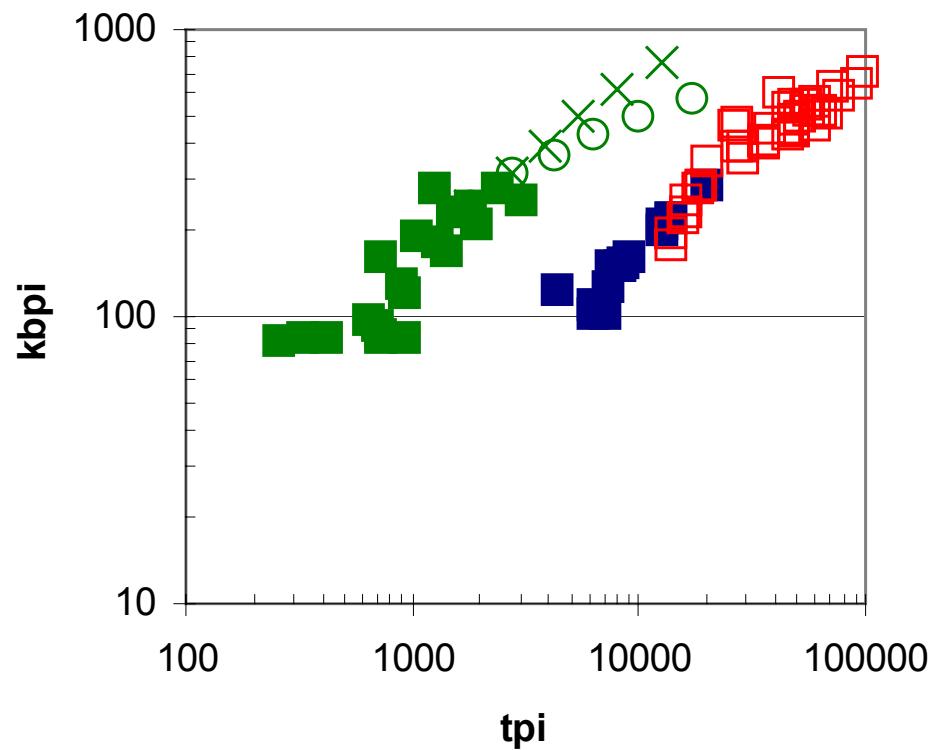
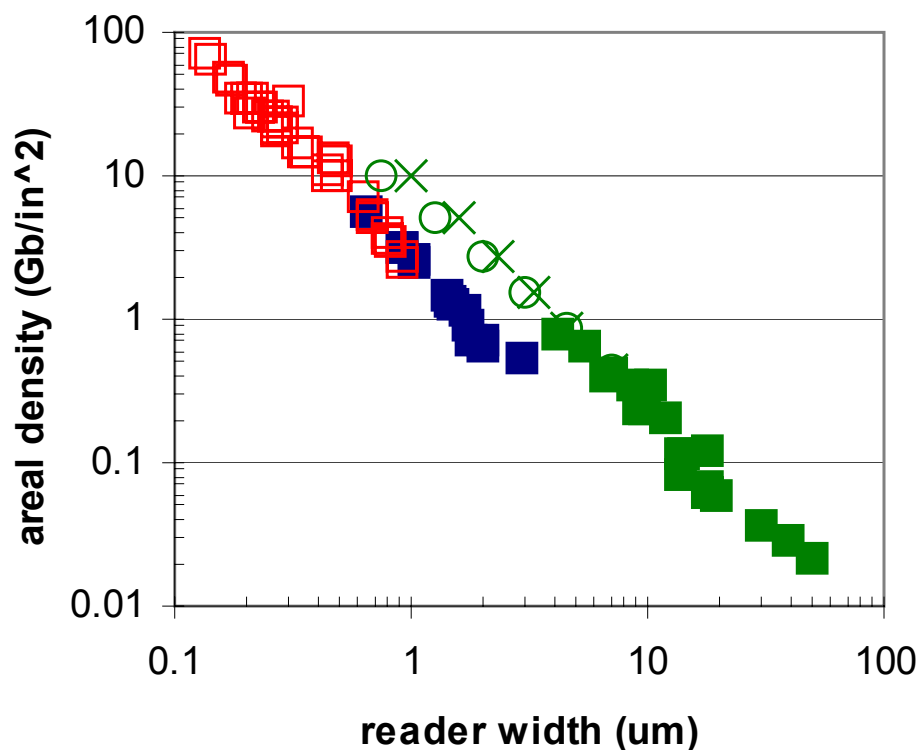
INSIC high bpi scenario

~ 12 year technology offset

Areal Density

2005 INSIC roadmap

- Disk - AMR
- Disk - GMR
- Tape
- × Tape (high bpi)
- Tape (high tpi)

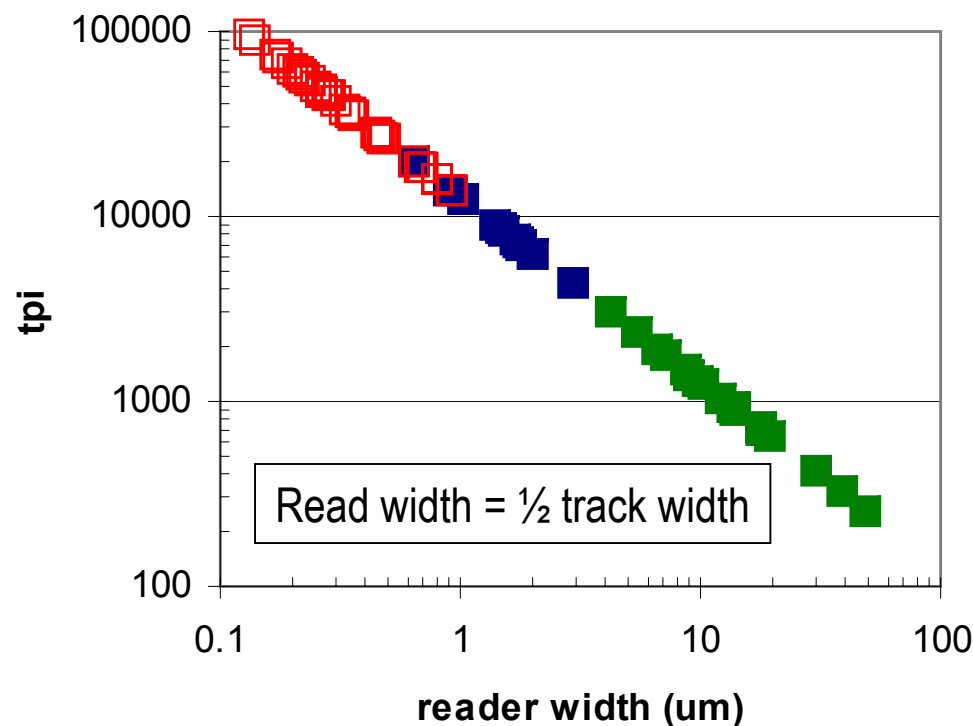
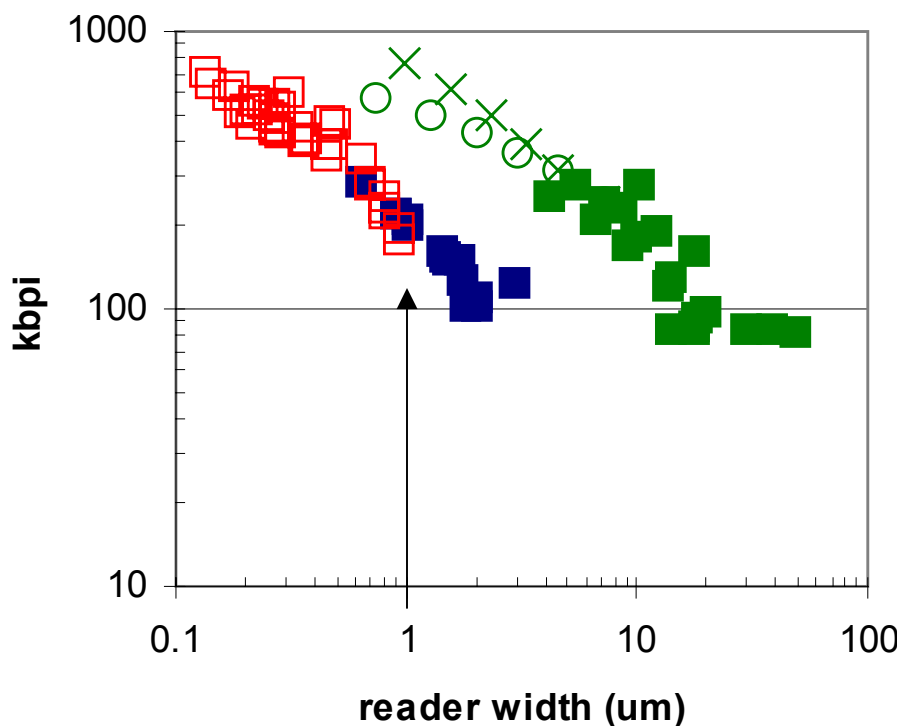


- Disk change to GMR ~ 2 - 5 Gb/in²
- Tape change to GMR ~ 1 - 2 Gb/in²

Kbpi and Tpi

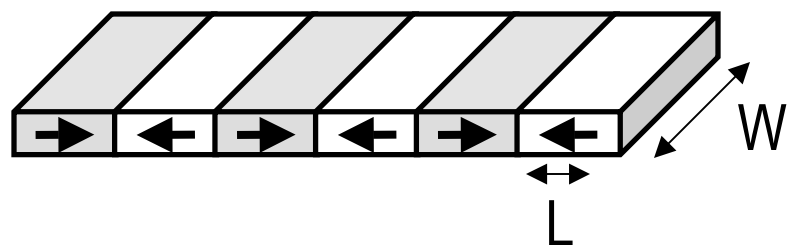
2005 INSIC roadmap

- Disk - AMR
- Disk - GMR
- Tape
- × Tape (high bpi)
- Tape (high tpi)



- Disk change to GMR ~ 1 μm , but only at 200 kbpi
- Tape change to GMR ~ 2 - 3 μm , but only at 300 - 400 kbpi

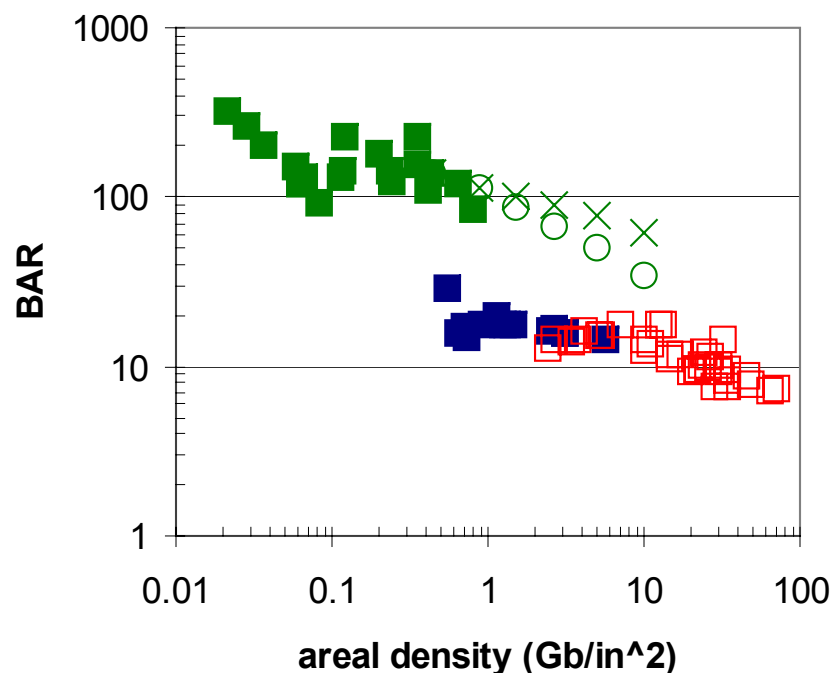
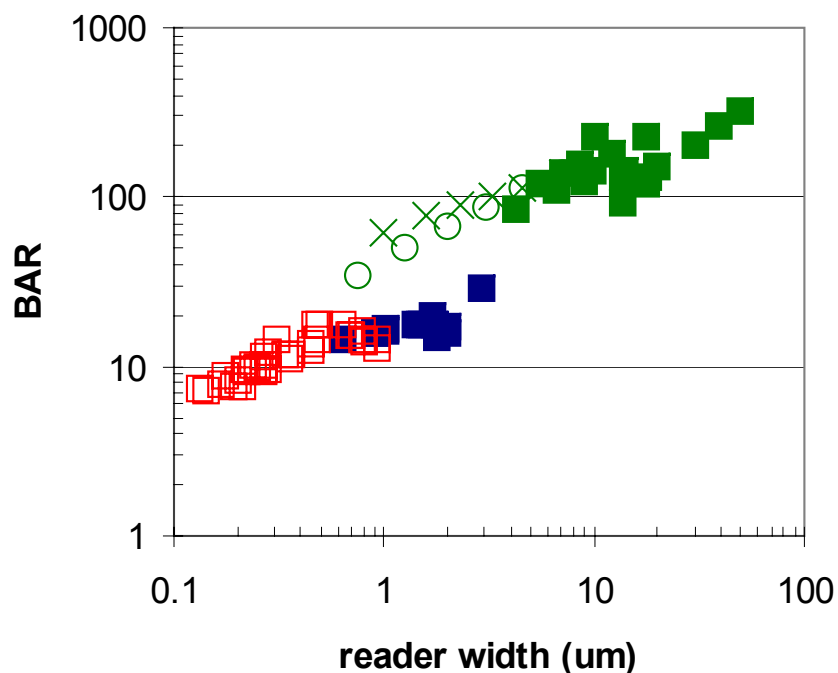
Bit Aspect Ratio (BAR)



$$\text{BAR} = \text{bpi}/\text{tpi}$$

$$= W/L$$

- Disk - AMR
- Disk - GMR
- Tape
- × Tape (high bpi)
- Tape (high tpi)



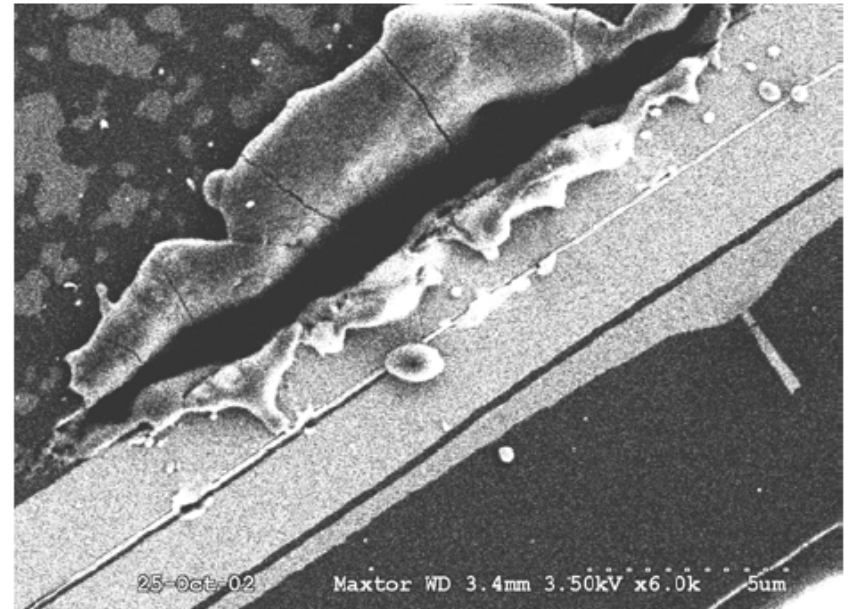
Tape has much higher BAR since bpi is pushed more

Similarities and Differences

- Similarities
 - > Fundamental physics of recording is identical
- Differences
 - > Interchange is needed for tape
 - > Disk is a “closed” environment compared to tape
 - > Contamination and corrosion
 - > Tape does read while write
 - > Area (18,000 in² vs. 8 in²)
 - > Rigid disk vs. flexible tape media (sputtered vs. particulate)
 - > Number of tracks
 - > 32 data + 4 servo tracks in Sun T10000 drive (crosstalk is a major issue)
 - > But disk can have lots of platters (5 two-sided disks with 10 heads)
 - > Manufacturing yield: tape, 36/36 with 36 tracks, disk, 1/1
 - > (device yield)³⁶ = head yield
 - > (83% device yield)³⁶ = 0.1% head yield
 - > (99.5% device yield)³⁶ = 83% head yield

Electro-Static Discharge

- GMR sensors are extremely sensitive to ESD
- Two failure modes
 - High temperatures melt and fuse materials together
 - Moderate temperatures heat PtMn anti-ferromagnet above it's blocking temperature
 - PtMn can reorient ~ 350° C
 - NiFe free layer ~ 660 ° C
 - Cu spacer ~ 1000 ° C



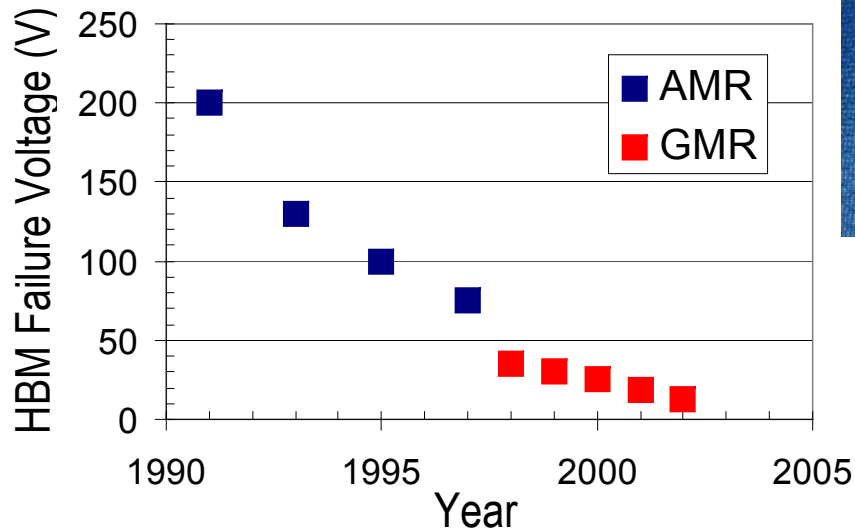
(Al Wallash – Maxtor Corporation)

ESD Sensitivity

- Hard drive
 - > Preamp on slider
- Tape
 - > Long flex to preamp



2006 Maxtor hard drive
Sun T10000 head, flex, and voice coil



(AI Wallash – Maxtor Corporation)

Conclusion

- Fundamental physics will drive the transition from AMR to GMR in tape just as it did in disk
 - > Disk migrated at 2 – 5 Gb/in², ~ 200 kbp, and 1 μm reader width
 - > Tape will migrate ~ 1 – 2 Gb/in², ~ 300 – 400 kbp, and 2 – 3 μm reader width
- Engineering tradeoffs have pushed disk to high tpi and tape to (relatively) high bpi due to track following issues in tape
- Disk migrated to GMR successfully (and then TMR)
- Tape will migrate to GMR but issues exist
 - > Corrosion
 - > ESD
 - > Media

Questions?